

# **2016 29th International Vacuum Nanoelectronics Conference (IVNC 2016)**

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**08:00-10:00 Registration**

**10:00-10:30 Breakfast and welcome address**

**10:30-12:00 Tutorial 1: theory and modeling of field-electron emitters**

- 10:30 Tutorial T1.1 (35+10 min): Field electron emission theory for metals and semiconductors N/A  
*R. G. Forbes  
University of Surrey, UK*
- 11:15 Tutorial T1.2 (35+10 min): Atomic-level modeling of cold field electron emission, using carbon as an example N/A  
*Z. Li  
Sun Yat-sen University, China*

**12:00-14:00 Lunch and networking**

**14:00-15:30 Tutorial 2: theory and modeling of photo-electron emitters**

- 14:00 Tutorial T2.1 (35+10 min): An introduction to photoemission: theory and modeling N/A  
*K. L. Jensen  
Naval Research Laboratory, USA*
- 14:45 Tutorial T2.2 (35+10 min): Photoemission of electrons from sharp needle tips driven by femtosecond laser pulses: a tutorial N/A  
*P. Hommelhoff  
Friedrich-Alexander University Erlangen-Nuremberg, Germany*

**15:30-16:00 Coffee break**

**16:00-17:30 Tutorial 3: theory and modeling of thermal electron emitters**

- 16:00 Tutorial T3.1 (35+10 min): Thermionic emission theory: a tutorial N/A  
*T. R. Groves  
University at Albany, State University of New York, USA*
- 16:45 Tutorial T3.2 (35+10 min): Thermionic emission for novel materials and its thermal relevance on other emission mechanisms N/A  
*L. K. Ang  
Singapore University of Technology and Design, Singapore*

**17:30-18:00 Free time**

**18:00-19:30 Welcome reception**

**08:00-08:30 Breakfast and registration****08:30-10:15 Photo-emission 1: ultra-fast emitters**

- 08:30 Plenary PE1.P1 (35+10 min): Harnessing photoionization or photo-recombination to create attosecond science and technology N/A

*P. B. Corkum*

*University of Ottawa and National Research Council, Canada*

- 09:15 PE1.C1 (15+5 min): An exact formulation for ultrafast electron emission due to a DC bias and a laser field 1

*P. Zhang, Y. Y Lau*

*University of Michigan, USA*

- 09:35 PE1.C2 (15+5 min): Electron emission from nanostructures triggered by optical and terahertz ultrafast pulses 3

*M. Monshipouri, Y. Abdi, Y. Oh, S. Bagiante, V. Guzenko, S. Tsujino, F. Brunner, T. Feurer*

*University of Tehran, Iran; Paul Scherrer Institute, Switzerland; University of Bern, Switzerland*

- 09:55 PE1.C3 (15+5 min): Field emission from gated silicon field emitter array induced by sub-nanosecond laser pulses 5

*H. Shimawaki, Y. Neo, H. Mimura, M. Nagao, F. Wakaya, M. Takai*

*Hachinohe Institute of Technology, Japan; Shizuoka University, Japan; National Institute of Advanced Industrial Science and Technology, Japan; Osaka University, Japan*

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*S. Mingels, V. Porshyn, P. Serbun, D. Lützenkirchen-Hecht, G. Müller, C. Prommesberger, C. Langer, R. Schreiner*

*University of Wuppertal, Germany; OTH Regensburg, Germany*

- 10:50 PE2.C2 (15+5 min): Delayed photo-emission model for PIC codes N/A

*K. L. Jensen, J. J. Petillo, D. Panagos, S. Ovchinnikov, N. A. Moody*

*Naval Research Laboratory, USA; Leidos Corp., USA; Gnosys, Inc., USA; Los Alamos National Laboratory, USA*

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*G. Hirsch*

*Hirsch Scientific, USA*

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*Y. Gotoh, H. Tsuji, M. Nagao, T. Masuzawa, Y. Neo, H. Mimura, T. Okamoto, M. Akiyoshi, N. Sato, I. Takagi*

*Kyoto University, Japan; National Institute of Advanced Industrial Science and Technology, Japan; Shizuoka University, Japan; National Institute of Technology, Japan; Osaka Prefecture University, Japan*

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**WEDNESDAY, 13 JULY 2016****08:00-08:30 Breakfast and registration****08:30-10:15 Field-emission 1: vacuum nanoelectronic devices**

- 08:30 Plenary FE1.P1 (35+10 min): Nanoscale vacuum electronic devices N/A  
*M. Meyappan*  
*NASA Ames Research Center, USA*
- 09:15 FE1.C1 (15+5 min): The enhancement of the electron field emission behavior of diamond/CNTs materials via the plasma post-treatment process for the applications in triode-type vacuum field emission transistor 13  
*D. Manoharan, H.-T. Chang, I-N. Lin, T.-H. Chang, P.-Y. Hsieh, S. Kunuku, K.-C. Leou, C.-Y. Lee, N.-H. Tai, Tamkang University, Taiwan; NTHU, Taiwan*
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*Peking University, China*
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*Naval Research Laboratory, USA*

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- 10:30 Invited FE2.I1 (20+10 min): Application of ultra-high-brightness nano-emitter for electron microscopes N/A  
*H. Zhang, J. Tang, Y. Yamauchi, L.-C. Qin*  
*National Institute for Materials Science, Japan; University of North Carolina Chapel Hill, USA*
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*Sun Yat-sen University, China*
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*Korea University, Korea; ETRI, Korea*
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*Savitribai Phule Pune University, India; Centre for Materials for Electronics Technology, India; CSIR-National Chemical Laboratory, India*

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*J. T. W. Yeow*  
*University of Waterloo, Canada*
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*M. Cahay, W. Zhu, K. L. Jensen, R. G. Forbes, S. B. Fairchild, T. C. Back, G. Gruen, T. Murray, J. R. Harris, D. A. Shiffler*  
*University of Cincinnati, USA; Naval Research Laboratory, USA; University of Surrey, UK; Air Force Research Laboratory, USA; University of Dayton, USA*
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*Thales Electron Devices, France; Thales Research and Technology, France*
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*J. Xu, Q. Wang, Z. Qi, Y. Zhai, X. Zhang*  
*Southeast University, China*

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*D. B. Go*  
*University of Notre Dame, USA*
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*California Institute of Technology, USA*
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*Creative Microsystems, Inc., USA; Massachusetts Institute of Technology, USA*
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*T. Grzebyk, A. Górecka-Drzazga, J. A. Dziuban*  
*Wroclaw University of Science and Technology, Poland*

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- 08:30 Plenary TEC.P1 (35+10 min): Thermoelectronic energy conversion - A large-scale nano-application? N/A  
*J. Mannhart, R. Wanke, I. Rastegar, W. Voesch, W. Braun  
 Max Planck Institute for Solid State Research, Germany*
- 09:15 Invited TEC.II (20+10 min): Wafer-scale thermionic energy converters N/A  
*R. T. Howe  
 Stanford University, USA*
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*F. A. Koeck, R. J. Nemanich  
 Arizona State University, USA*
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*K. Dridi, A. H. Khoshaman, A. Nojeh, G. A. Sawatzky  
 University of British Columbia, Canada*

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- 10:30 Invited MD1.I1 (20+10 min): The applications of super-aligned carbon nanotubes in vacuum electronics N/A  
*P. Liu, Y. Wei, L. Liu, S. Fan, K. Jiang  
 Tsinghua University, China*
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 Thales Research and Technology, France; Thales Electron Devices, France; CEA-LIST LCD, France*
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 Modern Electron, USA*
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*K. Murakami, M. Nagao, S. Tanaka, T. Iijima, J. Fujita, Y. Nemoto, M. Takeguchi  
 AIST, Japan; University of Tsukuba, Japan; NIMS, Japan*

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*M. Haider  
CEOS GmbH, Germany; Karlsruhe Institute of Technology, Germany*
- 09:15 Invited MD2.I1 (20+10 min): Using ultra-bright electron sources to analyze matter atom-by-atom N/A  
*O. L. Krivanek, N. J. Bacon, N. Dellby, T. C. Lovejoy  
Nion Co., USA; Arizona State University, USA*
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*Y. Saito, S. Oishi, S. Yamazaki, H. Nakahara, H. Murata, T. Ohno  
Nagoya University, Japan; Meijo University, Japan; Technex Lab Co., Japan*
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*Y. Sun, Y. Li, J. T. W. Yeow  
University of Waterloo, Canada*

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*D. J. Baek, R. Hovden, B. H. Savitzky, I. El Baggari, P. Liu, S. H. Sung, L. F. Kourkoutis  
Cornell University, USA*
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*K. K. Berggren, N. Abedzadeh, A. Agarwal, C.-S. Kim, R. Hobbs, P. Kruit, Y. Yang  
Massachusetts Institute of Technology, USA; Delft University of Technology, Netherlands*
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University of Dayton, USA; Air Force Research Laboratory, USA; Commissariat à l'Energie Atomique, France; Université de ParisSud/Orsay, France; Ecole des Mines de Paris, France; Ohio University, USA; Lawrence Berkeley National Laboratory, USA; NASA Glenn Research Center, USA*

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Euclid TechLabs LLC, USA; Argonne National Laboratory, USA*
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Paul Scherrer Institute, Switzerland; National Institute of Advanced Industrial Science and Technology, Japan; Max Planck Institute for the structure and Dynamics of Matter, Germany*
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ETRI, Korea; UST, Korea*
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Ketek GmbH, Germany; OTH Regensburg, Germany*

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Academia Sinica, Taiwan*
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Sun Yat-sen University, China*

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Massachusetts Institute of Technology, USA*

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Southeast University, China*

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Sun Yat-sen University, China*

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University of Ulsan, Korea; Pennsylvania State University, USA*

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University of Ulsan, Korea*

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*S. B. Fairchild, D. Marincel, T. C. Back  
Air Force Research Laboratory, USA; Rice University, USA; University of Dayton, USA*

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*R. G. Forbes  
University of Surrey, UK*

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*R. G. Forbes, A. A. Al-Qudah, S. Alnawasreh, M. A. Madanat, M. S. Mousa  
University of Surrey, UK; Mu'tah University, Jordan*

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*R. G. Forbes  
University of Surrey, UK*

P1.11. On the physical electrostatics of finite field emitter arrays N/A

*R. G. Forbes  
University of Surrey, UK*

P1.12. Testing Fowler-Nordheim-type equations N/A

*R. G. Forbes, J. H.B Deane  
University of Surrey, UK*

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*H.-S. Jeong, K. Keller, B. Culkin  
University of Suwon, Korea; Photegra Corporation, USA*

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*H.-S. Jeong, K. Keller, B. Culkin  
University of Suwon, Korea; Photegra Corporation, USA*

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*D. Manoharan, I-N. Lin, Loganathan  
Tamkang University, Taiwan; National Tsing Hua University, Taiwan*

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University of British Columbia, Canada*
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Southeast University, China; Nanjing University of Posts and Telecommunications, China*

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University of Cincinnati, USA; University of Surrey, UK; Air Force Research Laboratory, USA; University of Dayton, USA*

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University of British Columbia, Canada; Stanford University, USA*

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OTH Regensburg, Germany; Sun Yat-sen University, China*

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*K. L. Jensen, D. A. Shiffler, J. R. Harris, I. M. Rittersdorf, J. J. Petillo  
Naval Research Laboratory, USA; Air Force Research Laboratory, USA; Leidos, USA*

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